

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	9775	(250/492.1-492.3).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/26 13:05
L2	86	L1 and pattern\$4 same mask same substrate and stage and detect\$4 with stage and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:05
L3	36	L1 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:09
L4	33	L1 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:15

L5	24	L1 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:17
L6	9	L1 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:28
L7	9	@ad<"20050112" and L1 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:30

L8	0	@ad< "20050112" and L1 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibration with rais\$4 and vibration with low\$4	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:34
L9	0	@ad< "20050112" and L1 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibrat\$4 with rais\$4 and vibrat\$4 with low\$4	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:34
L10	1	@ad< "20050112" and L1 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:35

		or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibrat\$4 with (rais\$4 or low\$4)				
L11	1	@ad< "20050112" and L1 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibrat\$4 with (rais\$4 or low\$4) and liquid	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:38
L14	0	@ad< "20050112" and L1 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibrat\$4 with (rais\$4 or low\$4) and liquid and ("3" or three) with degree \$4 with freedom	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 13:54

L15	1	@ad<"20050112" and L1 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate and liquid same (optical with (column or body))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 15:18
L16	0	@ad<"20050112" and L1 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate and liquid with liquid with (optical with (column))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:28
L17	0	@ad<"20050112" and L1 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate and liquid with (optical with (column))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:29
L18	0	@ad<"20050112" and L1 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate and liquid with (optical with (column or body))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:30
L19	1	@ad<"20050112" and L1 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate and dry with immersion	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:31

L20	4	@ad<"20050112" and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate and dry with immersion	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:32
L21	4	@ad<"20050112" and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate and liquid with (column)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:33
L22	0	@ad<"20050112" and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate and liquid with (optical with column)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:33
L23	1	@ad<"20050112" and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate and liquid with (optical with (body or column))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:33
L24	0	@ad<"20050112" and L1 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:42

		\$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibrat\$4 with (rais\$4 or low\$4) and abnormal\$4				
L25	1	@ad<"20050112" and L1 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibrat\$4 with (rais\$4 or low\$4) and situation	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:43
L26	1	@ad<"20050112" and L1 and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibrat\$4 with (rais\$4 or low\$4) and (situation or problem\$4 or abnormalit \$4 or issue)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:47

L27	22	@ad<"20050112" and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibrat\$4 with (rais\$4 or low\$4) and (situation or problem\$4 or abnormalit \$4 or issue)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:48
L28	0	@ad<"20050112" and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and vibrat\$4 with (damp \$4 or isolat\$4 or minimiz \$4 or prevent\$4) and vibrat\$4 with (rais\$4 or low\$4) and (situation or problem\$4 or abnormalit \$4 or issue) and earthquake	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:50

L29	1	@ad<"20050112" and pattern\$4 same mask same substrate and stage and detect\$4 with stage with (locat\$4 or posit\$4 or place\$4 or point\$4) and stage with substrate with (hold\$4 or attach\$4 or secur\$4 or grip\$4 or fix\$4) and stage with perpendicular and stage with axis with (optical or beam) with (move\$4 or accelerat\$4 or speed\$4 or velocity) and earthquake	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 16:50
L30	1	(US-20070146663-\$).did.	US-PGPUB	ADJ	ON	2008/03/26 18:44
L31	1	(US-6654095-\$).did.	USPAT	ADJ	ON	2008/03/26 18:51
L32	5	I10 or I11 or I15 or I19 or I23 or I25 or 26 or I29 or I30 or I31	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/03/26 18:54
S1	954	(250/492.22).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/25 17:03
S2	9775	(250/492.1-492.3).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/25 17:04

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